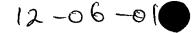
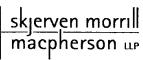
San Jose California 95110



T: 408-453-9200 F: 408-453-7979 Austin, TX Newport Beach, CA San Francisco, CA



758.00

\$

Docket No.: M-11021 US

November 1, 2001

Box Patent Application Commissioner For Patents Washington, D. C. 20231

Enclosed herewith for filing is a patent application, as follows:

Inventors: Entley, William R.; Langan, John G; Hall, Randy;.

Title: In Situ Plasma Process To Remove Fluorine Residues From The Interior Surfaces Of A

CVD Reactor

X Return Receipt Postcard

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This Transmittal Letter (in duplicate)
pages Specification(not including claims)

pages Claims
page Abstract

4 Sheets of Drawings

3 pages Declaration For Patent Application and Power of Attorney

1 page NonPublication Request

1 pages Recordation Form Cover Sheet (in duplicate)

2 pages Assignment

page Information Disclosure Statement
page PTO Form 1449 citing 7 references
Copies of 7 Cited References submitted

## **CLAIMS AS FILED**

	Number			Number					Basic Fee
<u>For</u>	<u>Filed</u>			<u>Extra</u>		Rate		\$	<u>740.00</u>
Total Claims	21	-20	=	1	x	\$18.00	=	\$	18.00
Independent	1	-3	=	0	х	\$84.00	=	\$	0.00
Claims									
Fee of for the first filing of one or more								\$	
multiple dependent claims per application									
Fee for Request for Extension of Time \$									
Please make the following charges to Deposit Account 19-2386:									

☐ Total fee for filing the patent application in the amount of
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The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account 19-2386.

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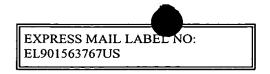
Respectfully submitted,

David E. Steuber Attorney for Applicants

Reg. No. 25,557

A

10/003908 10/003908 11/01/01



MODIFIED PTO/SB/35 (11-00)

## REQUEST AND CERTIFICATION UNDER 35 U.S.C. 122(b)(2)(B)(i)

Inventors		Entley, William R.; Langan, John G.; Hall, Randy					
Title	In Situ Plasma Process To Remove Fluorine Residues From The Interior Surfaces Of A CVD Reactor						
Atty Docket Number			M-11021 US				

I hereby certify that the invention disclosed in the attached application has not and will not be the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing. I hereby request that the attached application not be published under 35 U.S.C. 122(b).

November 1, 2001 Date

David E. Steuber Attorney for Applicants Reg. No.: 25,557

This request must be signed in compliance with 37 CFR 1.33(b) and submitted with the application **upon filing**.

Applicant may rescind this nonpublication request at any time. If applicant rescinds a request that an application not be published under 35 U.S.C. 122(b), the application will be scheduled for publication at eighteen months from the earliest claimed filing date for which a benefit is claimed.

If applicant subsequently files an application directed to the invention disclosed in the attached application in another country, or under a multilateral international agreement, that requires publication of applications eighteen months after filing, the applicant must notify the United States Patent and Trademark Office of such filing within forty-five (45) days after the date of the filing of such foreign or international application. Failure to do so will result in abandonment of this application (35 U.S.C. 122(b)(2)(B)(iii)).